OLD E COLOR

Sheet __1__ of ___2__

Force 1449 (Modified)						Atty. Docket 27/217	Application No. 10/632,955					
INFORMATION DISCLOSURE CITATION IN AN APPLICATION (USE SEVERAL SHEETS IF NECESSARY)							Applicant: Nathan et al					
							Filing Date: 04 Aug 2	Group Art Unit: 2913				
U.S. PATENT DOCUMENTS												
	EXAMIN INITIAL	ER	DOCUMENT NUMBER	T DA	TE	NAME				CLASS	SUB- CLASS	FILING DATE
AA	My		6,580,547	Jun ()3	Liu et al						
AB	Am,	2	6,444,133	Sep	02	Fajardo et al						
AC	ml	2	6,472,804	Oct ()2	Mueller et al						
AD	m	2	6,542,682	Apr	03	Cotteverte et al						
FOREIGN PATENT DOCUMENTS												
		DOCUMENT NUMBER		DATE	. (COUNTRY	CLASS	SUB-CI	LASS	TRANSLATION	
		_		<u></u>			•			```	YES	NO
AE		,		*. ,				,				
			ОТНЕ	R ART (Includir	ng A	uthor, Title,	Date, Pertinent l	Pages, E	tc.)		
AF	Mis	A Three Dimensional Optical Photonic Crystal, Lin et al, Journal Of Lightwave Technology Vol.17, no.11 Nov '99										
AG	ms	Quasimetallic silicon micromachined photonic crystals, Temelkuran et al, Appl. Physics Letters, Vol. 78, no. 3 Jan 2001 pp 264-266										
АН	mls	Fabrication of Photonic Crystals Consisting of Si Nanopillars By Plasma Etching Using Self-Formed Masks, Tada et al, pp 7253-7256, Jpn J Appl Phys, Vol 38 (1999) Pt 1, No. 12B										
Al	mo	Fabrication of two-dimensional photonic crystal waveguides for 1.5um in silicon by deep anisotropic dry etching, Zijlstra et al; 1999 American Vacuum Society pp2734-2739										
AJ Investigation of a channel-add/drop-filtering device using acceptor-type point defects in a two-dimensional photonic-crystal slab, Asano et al; Applied Physics Letters vol 83 No. 3 July 2003, pp407-409												
EXAMINER (MELLE MATE CONSIDERED) / WOS												
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformation and not considered. Include copy of this form with next communication to applicant.												

Sheet _2_ of2_												
		(Modified)	SEP 1 5 2003 3	2	tty. Docket 7/217	l No.		Application No. 10/632,955				
	J	IN AN APPLICA	SURE CITATION	l N	Applicant: Nathan et al							
	·			Filing Date: 04 Aug 2003			Group A	Group Art Unit: 2813				
U.S. PATENT DOCUMENTS												
	EXAMIN INITIAL					NAMÉ	CLASS	SUB- CLASS	FILING DATE			
ВА												
ВВ												
FOREIGN PATENT DOCUMENTS												
		DOCUMENT NUMBER	DATE	COU	JNTRY	CLASS	SUB-	CLASS	TRANSLATION			
									YES	NO		
вс												
	A	ОТН	ER ART (Includi	ing Auth	or, Title,	Date, Pertinent	Pages,	Etc.)				
BD ¿	1/1/10	Electrooptical Effects in Silicon, Soref et al; Jl of Quantum Electronics, vol. QE-23, no. 1 Jan 87 pp.123-129										
BE (ms	Fabrication of a narrow gold wire using scanning tunneling microscopy; Okamoto et al; , Jpn J Appl Phys, Vol 36 (1997) Pt 1, No. 6B pp.3832-3833										
BF (Mr	Fabrication and direct transmission measurement of high-aspect-ratio two-dimensional silicon-based photonic crystal chips, Xu et al, J Opt Soc Am B/Vol 18 No. 8 August 2001pp.1084-1091										
BG (my	Defect Modes in Two-Dimensional Triangular Photonic Crystals. X. P. Feng et al, Jpn. J. Appl. Phys., 36 pp. L120-L123, 1997										
ВН	my	Narrow Band Microcavity Waveguides In Photonic Crystals, Boag et al, J. Opt. Soc. Am. A, 18(11) pp. 2799-2805, 2001										
ВІ	my	Bipolar Semiconductor Devices; Roulston; Section 3.5.2, Mc-Graw Hill 1990, ISBN 0-07-054120-5,										
BJ (mu	Photonic Crystals: putting a new twist on light, Joannopoulus et al., Nature, vol. 386, Mar. 13, 1997, pp. 143-149										
ВК	My	Design And Sensitivity Analysis Of Narrow Band Photonic Waveguides, Boag et al, URSI Radio Science Meeting, Boston, MA, July 2001, pp 33-35										
BL	my	Chapter 55 of the "Complete guide to semiconductor devices" by Kwok K. Ng, Mc-Graw Hill, 1995, ISBN 0-07-035860-5, pp 441-445										
ВМ	BM Chapter 15 of the "Complete guide to semiconductor devices" by Kwok K. Ng, Mc-Graw Hill, 1995, ISBN 0-07-035860-5, pp. 132-143											
EXAMINER CONSIDERED 1/14/05												
EXAN	IINER: Init	ial if reference co	onsidered, whether	or not cit	ation is in	conformance with	MPEP	609; Draw	v line throug	gh citation		
If not i	n conforma	ition and not cons	sidered. Include cor	py of this	form with	next communicati	ion to a	pplicant.				